- 1				
		V.	DB	Time stamp
L	Hits	Search Text		
Number		"low k" same (etch\$4 or remov\$4) same	USPAT;	2002/08/08
1	13	(ammonia or "NH.sub.3")	EPO; JPO;	15:53
1		(ammonia or Wh. Sub. 3)	IBM TDB	
1		("fluorinated arylether" or "poly arylene	USPAT;	2002/08/08
3 /	5733	ether" or flare or silk or "low k") and	EPO; JPO;	16:01
'		(etch\$4 or remov\$4 ) and (ammonia or	IBM TDB	
a.		"NH.sub.3")	_	<u> </u>
		("fluorinated arylether" or "poly arylene	USPAT;	2002/08/08
2	87	ether" or flare or silk or "low k") same	EPO; JPO;	16:31
1,2		(etch\$4 or remov\$4 ) same (ammonia or	IBM_TDB	<b>i</b>
! !		"NH.sub.3")	_	
}	17040	l	USPAT;	2002/08/08
4	17849	or "H.sub.2") same (nitrogen or	EPO; JPO;	16:35
1		"N.sub.2")	IBM_TDB	
-	1	N.3ub.2	USPAT	2002/08/08
6	_			16:17
_	290	( (ammonia or "NH.sub.3") same (hydrogen	USPAT	2002/08/08
7	230	or "H. sub. 2") same (nitrogen or		16:24
ì		"N.sub.2")) same (dielectric or	1	
	1	insulating)	·	2002/08/08
8	1880	1	USPAT;	2002/08/08
8	1000	(438/720)).CCLS.	EPO; JPO;	16:25
1			IBM_TDB	2002/08/08
11	169	( (ammonia or "NH.sub.3") same (hydrogen	USPAT;	16:35
1		or "H.sub.2") same (nitrogen or	EPO; JPO;	10.33
		"N sub 2")	IBM_TDB USPAT;	2002/08/08
12	3894	(ammonia or "NH.sub.3") same (hydrogen	EPO; JPO;	16:43
	1	or "H. sub.2") same (nitrogen or	IBM TDB	10
1		"N sub 2") same (etch\$4 or remov\$4)	USPAT;	2002/08/08
13	7489	(opening or via or contact) same	EPO; JPO;	16:40
		sidewalls same (angle or tapered)	IBM TDB	
		, and and	USPAT;	2002/08/08
16	612	((opening or via or contact) same	EPO; JPO;	16:45
		sidewalls same (angle or tapered)) same	IBM TDB	
1	1	etch\$4		